FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTORNEY DOCKET NO.

ATION NO. 09/339,199

21.1931 FIRST NAMED INVENTOR

Fumiaki NAKATAKE et al.

FILING DATE

GROUP ART UNIT

(Use several sheets if necessary)

LIST OF REFERENCES CITED BY APPLICANT

June 24, 1999

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U.S. PATENT DOCUMENTS

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OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

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|-----|----|---|
| KIN | АМ | Nagahata, Akihiro et al., "Present and future of sealing and exhausting process in plasma display panel manufacturing", Technical Report of Plasma Display, April 1999, pages 45-51 (English translation of relevant portions). |
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EXAMINER

KENNETH J. RAMSEY PRIMARY EXAMINER

DATE CONSIDERED

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